



MAGNESIUM FLUORIDE SPUTTERING TARGET

Magnesium fluoride sputtering target from Stanford Advanced Materials is an inorganic compound with the formula MgF₂. The main application of magnesium fluoride is in optics, due to its distinctive transparency over a wide range of wavelengths. It is evaporated under vacuum to form anti-reflective layers.

Quick Facts

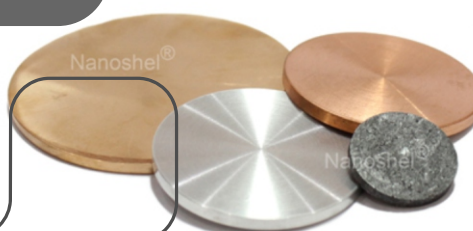
Product	:	Magnesium Fluoride Sputtering Target
Stock No	:	NS6130-10-1142
CAS	:	7783-40-6
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1142	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
MgF ₂	62.3018g/mol	1263°C



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19ZAZGO1274G

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High Purity
SPUTTERING
TARGET